

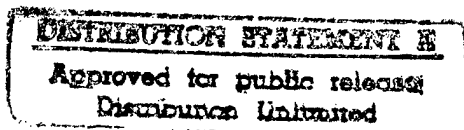
**Progress Report**

Item No: 0001AB

**Title of the Project:**

Optimization of Properties of a New Material for Electronic and  
Magnetic Applications

<b>Topic No.:</b>	BMDO 97-014
<b>Contract No.:</b>	N00014-97-C-0209
<b>Contract Starting Date:</b>	May 14, 1997
<b>Contract Ending Date:</b>	December 14, 1997
<b>Contractor:</b>	SKION Corporation 50 Harrison Street Hoboken, NJ 07030



**Prepared By:**  
Dr. Steven Kim  
Principal Investigator  
SKION Corporation  
**Report Date: August 14, 1997**

19970912 037

DTIC QUALITY INSPECTED 3

# REPORT DOCUMENTATION PAGE

Form Approved  
OMB No. 0704-0188

Public reporting burden for this collection of information is estimated to average 1 hour per response, including the time for reviewing instructions, searching existing data sources, gathering and maintaining the data needed, and completing and reviewing the collection of information. Send comments regarding this burden estimate or any other aspect of this collection of information, including suggestions for reducing this burden, to Washington Headquarters Services, Directorate for Information Operations and Reports, 1215 Jefferson Davis Highway, Suite 1204, Arlington, VA 22202-4302, and to the Office of Management and Budget, Paperwork Reduction Project (0704-0188), Washington, DC 20503.

1. AGENCY USE ONLY (Leave Blank)	2. REPORT DATE 14 Aug 97	3. REPORT TYPE AND DATES COVERED Interim 15 Jul 97 - 14 Aug 97
----------------------------------	-----------------------------	---

4. TITLE AND SUBTITLE Optimization of Properties of a New Material for Electronic and Magnetic Applications	5. FUNDING NUMBERS Contract N00014-97-C-0209
--	--

6. AUTHOR(S)  
  
Dr. Steven Kim

7. PERFORMING ORGANIZATION NAME(S) AND ADDRESS(ES)  
  
SKION Corporation  
50 Harrison Street  
Hoboken, NJ 07030

8. PERFORMING ORGANIZATION REPORT NUMBER  
  
SKI 0002

9. SPONSORING/MONITORING AGENCY NAME(S) AND ADDRESS(ES)  
  
DCMC Springfield  
Bldg 1 ARDEC  
Picatinny, NJ 07086-5000

10. SPONSORING/MONITORING AGENCY REPORT NUMBER

11. SUPPLEMENTARY NOTES

12a. DISTRIBUTION/AVAILABILITY STATEMENT

12b. DISTRIBUTION CODE

13. ABSTRACT (Maximum 200 words)

Several test samples were grown at the City College of New York MBE facility. The exact growth rate is unknown at present, but the nominal thickness are 12.5, 25, and 50 nm MnAs on 100 nm buffer layers of GaAs.

The substrate orientations are (001). GaAs buffer layers are p-type with a carrier concentration of  $\sim 5 \times 10^{17} \text{ cm}^{-3}$  and a thickness of  $\sim 100 \text{ nm}$ . The nominal growth rate of MnAs was 50 nm/hour. Flux ratio of As/Mn was about 5-10. All the layers were annealed at 400°C for 1 minute after the growth (the time for increasing growth temperature from 250°C to 400°C was about 4 minutes).

Growth temperatures and growth times for MnAs layers are:

B94: 200C for 7 min. 30 sec.	250C for 42 min. 30 sec.
B95: 200C for 1 min.	250C for 30 min.
B96: 200C for 1 min.	250C for 14 min.

14. SUBJECT TERMS  
p-type flux ratio  
growth rate

15. NUMBER OF PAGES  
4

16. PRICE CODE

17. SECURITY CLASSIFICATION OF REPORT  
unclassified

18. SECURITY CLASSIFICATION OF THIS PAGE  
unclassified

19. SECURITY CLASSIFICATION OF ABSTRACT  
unclassified

20. LIMITATION OF ABSTRACT

We had access to MBE facility at City College of New York. We have grown several test samples. The exact growth rate is unknown at present, but the nominal thickness are 12.5, 25, and 50 nm MnAs on 100 nm buffer layers of GaAs.

The substrate orientations are (001). GaAs buffer layers are p-type with a carrier concentration of  $\sim 5 \times 10^{17} \text{ cm}^{-3}$  and a thickness of  $\sim 100 \text{ nm}$ . The nominal growth rate of MnAs was 50 nm/hour. Flux ratio of As/Mn was about 5-10. All the layers were annealed at 400°C for 1 minute after the growth (the time for increasing growth temperature from 250°C to 400°C was about 4 minutes).

Growth temperatures and growth times for MnAs layers are:

B94: 200C for 7 min. 30 sec.      250C for 42 min. 30 sec.

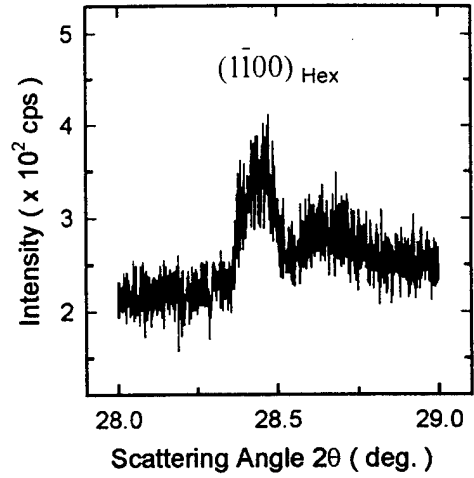
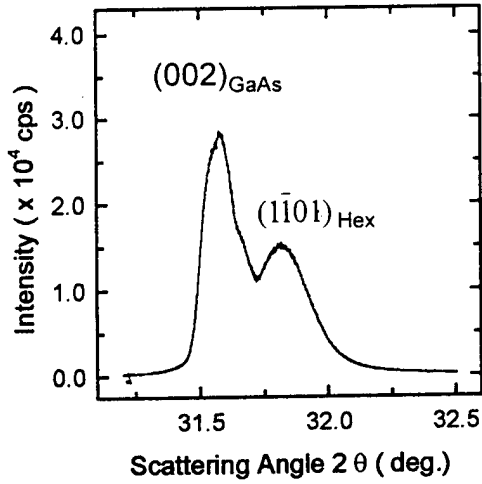
B95: 200C for 1 min.                250C for 30 min.

B96: 200C for 1 min.                250C for 14 min.

Next month, we will characterize the magnetic and optical properties of the samples: the effect of steady electric fields on hysteresis curves, MOKE and the index of refraction will be determined.

X-ray diffraction ( XRD ) spectra in  $\theta$ - $2\theta$  scan revealed that at room temperature the MnAs film have mainly hexagonal phase whose plane parallel to the surface was mostly  $(\bar{1}\bar{1}01)$  and partially  $(\bar{1}\bar{1}00)$  at room temperature. Small volume fraction of orthorhombic phase ( less then 4%) was also present in the film. It may be related to ununiform internal strain existed in the film. MnAs in bulk form takes the hexagonal structure and is ferromagnetic at room temperature and exhibits a first order phase transition at  $40^{\circ}\text{C}$  to a paramagnetic state with the orthorhombic structure. It is well known the magnetic properties and structure of MnAs are highly sensitive to pressure.

Although our first film was a mixture of hexagonal phases with two different growth orientation and orthorhombic phase, it can be controlled by changing growth conditions such as substrate temperature, Mn to As flux ratio and different thickness of GaAs buffer layer. Furthermore we presented that the easy direction of magnetization in film was controlled by predepositions of different first few atomic layer before growth of MnAs.



Typical XRD spectra of MnAs film in  $\theta$ - $2\theta$  scan mode. Miller indices of scattering are shown above peaks. The most intense peak at the left hand side is related to the (002) plane of GaAs substrate.